\*\*Image available\*\* 008370117

WPI Acc No: 1991-374144/199151

Optical equipment for artificial sunlight exposure apparatus - consists of mosaic filter chips differing in filtering characteristic NoAbstract

Dwg 1-3/6 Patent Assignee: KAZUHIRO TAKESHI (KAZU-N)

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Priority Applications (No Type Date): JP 9051373 A 19900302

Abstract (Basic): JP 3252604 A

A first layer comprising GeO2, a second layer comprising a complex of TiO2 and HfO2 or comprising TiO2, and a third layer comprising SiO2 are laminated successively on a synthetic resin optical component.

The synthetic resin optical component pref. comprises a polycarbonate resin. The first, second, and third layers are formed to have a thickness of 0.25 lambda to the design wavelength (lambda) of

applied light.

USE/ADVANTAGE - The anti-reflection film applies to synthetic resin optical components and finds its application in office automation machines, optical communications, optical information processing, or cameras. The film substances have high chemical and thermal stability. The anti-reflection film has good adhesion to the synthetic resin base material and maintains high reflectance, for a wide wavelength region, and features superior durability. (5pp Dwg.No.0/5)